The 22nd Korean Conference on Semiconductors (KCS 2015)

제22회 한국반도체학술대회

2015년 2월 10일(화)-12일(목), 인천 송도컨벤시아

G. Device & Process Modeling, Simulation and Reliability 분과

Room C 1F / 106호

2015년 2월 11일(수) 13:00-14:30 [WC2-G] Device Physics and Characterization 1

좌장: 신민철 (KAIST), 김대환 (국민대학교)

WC2-G-1	13:00-13:30	Comparison of Electrical Characteristics between NanoPlate FET and
		Nanowire FET for 5 nm node Technology
		Jong-su Kim, Duckseoung Kang, and Hyungcheol Shin
		School of Electrical Engineering and Computer Science, Seoul National
		University
WC2-G-2	13:15-13:30	Investigation of the Asymmetrical Degradation Behaviors under Various
		Gate and Drain Bias Stresses in a-InGaZnO Thin-Film Transistors
		Daeun Lee ¹ , Chan-Yong Jeong ¹ , Sang-Hun Song ¹ , Jin Xiao-Shi ² , and Hyuck-In
		Kwon ¹
		¹ School of Electrical and Electronics Engineering, Chung-Ang University,
		² School of Information Science and Engineering, Shenyang University of
		Technology
WC2-G-3	13:30-13:45	Various Heterojunction Single Gate Tunneling FETs with Graded Channel
		Doping in Sub-40 nm Channels
		Jungsik Kim ¹ , Hyeongwan Oh ² , Taiuk Rim ³ , Chang-Ki Baek ³ , and Jeong-Soo
		Lee ^{1,2}
		¹ Department of IT Convergence Engineering, POSTECH, ² Electrical
		Engineering, POSTECH, ³ Creative IT Engineering and Future IT Innovation
		Lab, POSTECH
WC2-G-4	13:45-14:00	Analysis of Structural Dependences on the Electrical Performance of
		Vertical Organic Field-Effect Transistor (VOFET)
		Juhee Lee, Bongsik Choi, Jinsu Yoon, Minsu Jeon, Jaeman Jang, Dong Myong
		Kim, Dae Hwan Kim, and Sung-Jin Choi
		Kookmin University
WC2-G-5	14:00-14:15	The High-k/Metal Gate Structure to Suppress GIDL and FIBL in MOSFET
		Esan Jang, Jaewon Jung, Sunhae Shin, and Kyung Rok Kim
		Department of Electrical and Computer Engineering, Ulsan National Institute
		of Science and Technology
WC2-G-6	14:15-14:30	2T SONOS Cell with a Low Voltage Select Gate for Random Access
		Operation

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Jaegwan Kim, Youngjun Kwon, Taeho Lee, Sunkun Park, Seongyong Sung, Inwook Cho, and Kyongdong Yoo Technology Development team, SK Hynix Inc.